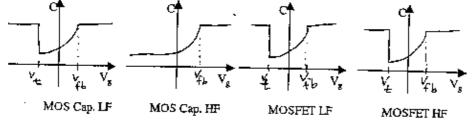
EE 130, Spring/2000 Midterm II Solutions Professor C. Hu

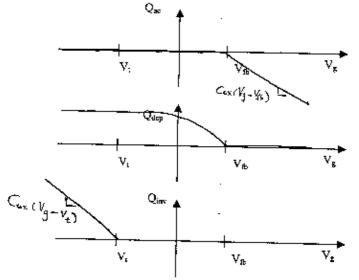
Problem #1

1. Consider a PMOSFET with a P+ poly-silicon gate and a N-type body. The body doping concentration is 2.0* 10^17cm^-3, and gate oxide thickness is 10nm. (**35 Points**)

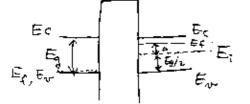
(a) Qualitatively sketch the C-V curve of MOS capacitor and MOSFET for high frequency and low frequency. (No need to calculate Vfb and Vt here) (7 pts)



(b) Draw charge vs gate voltage of PMOSFET qualitatively. (7 pts)



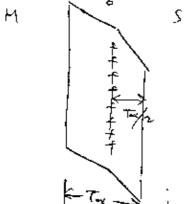
(c) Calculate the flat band voltage. (7 pts)

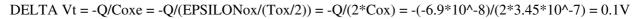


 $Vfb = Eg/2 + DELTA = Eg/2 + K*T/q * \ln(Nsub/Ni) = 0.55 + 0.026*\ln(2.0*10^{17}/(1.0*10^{10})) = 0.55 + 0.44 = 0.99V$

(d) Calculate the threshold voltage. (7 pts) Vt = Vfb - 2*PHIb - (2*EPSILONs*q*Nsub*2*PHIb)^.5/Cox PHIb = K*T/q * ln(Nsub/N1) = 0.44 (= DELTA in (d)) Cox = EPSILONox/Tox = $3.9*8.85*10^{-14}/10^{-6} = 3.45*10^{-7}$ (F/cm^2) Vt = $0.99-2*0.44-2.41*10^{-7}$)/($3.45*10^{-7}$) = -0.59V

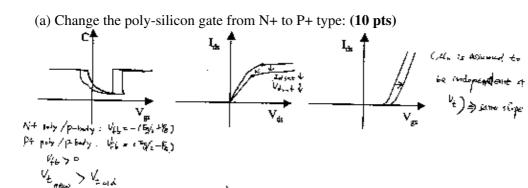
(e) A sheet of electrons $(6.9*10^{-8}C/cm^{2})$ is trapped at the center of the gate oxide. How much is the threshold voltage changed? (7 pts)



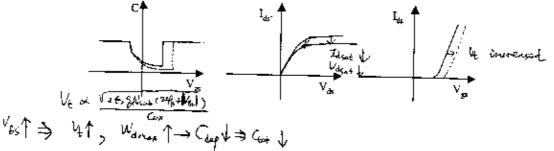


Problem #2

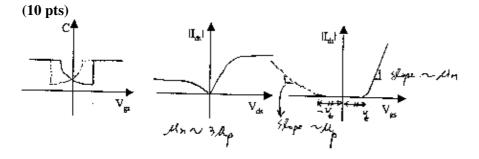
Qualitatively sketch the C-V, Id-Vg, and Id-Vd curves for an NMOSFET to indicate how the curves would differ in response to the changes given below. Assume the **mobility is fixed for (a) and (b). (30 pts)**



(b) Reverse back bias is applied to the body. (10 pts)

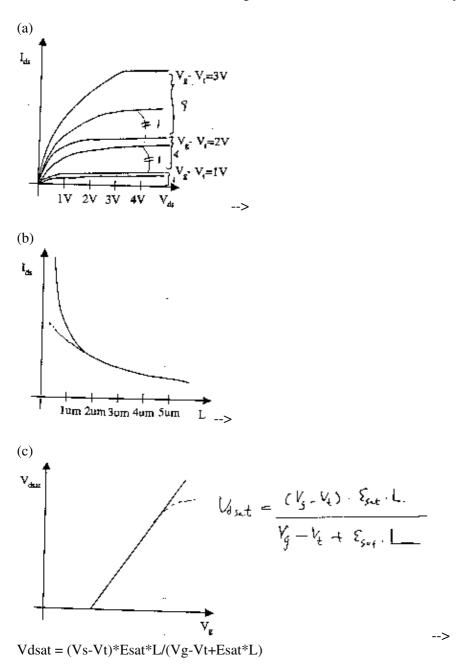


(c) Reverse the doping types of the source/drain, body, and gate, i.e. change from NMOSFET to PMOSFET. Select the proper quadrant. Source and body are tied to ground (0V). Consider MUn != MUp.



Problem #3

The printed curves in each of the figures are drawn for a MOSFET without consideration for velocity saturation. Draw new curves in each figure to indicate the effect of velocity saturation. (15 pts: 5 pts each)



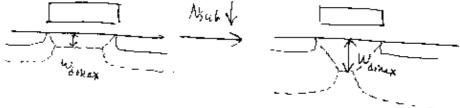
Problem #4

Indicate in the table below the consequences of decreasing the body doping concentration, Nsub, in and NMOSFET by checking two appropriate boxes (Increase/Decrease and Desirable/Undesirable) for each line. (20 pts)

	Increases	Decreases	Desirable	Undesirable	Points
Transconductance, Gmsat	X		Х		5 pts
Subthreshold swing, S		Х	Х		5 pts
Vt roll-off (Short channel effect)	Х			Х	5 pts
Body effect coefficient, ALPHA		Х	Х		5 pts

i)Gmsat = dIdsat/dVgs = MU*W*Cox/L * (Vg-Vt) Nsub down implies Vt down implies Gmsat up desirable

ii) $S = 60mV^*(1+Cdep/Cox)$ Nsub down implies Wdmax up implies Cdep down implies S down desirable iii)



Vt roll-off increases implies undesirable

iv) ALPHA = Cdep/Cox ; Nsub down ; Cdep down ; ALPHA down

Posted by HKN (Electrical Engineering and Computer Science Honor Society) University of California at Berkeley If you have any questions about these online exams please contact <u>examfile@hkn.eecs.berkeley.edu.</u>